

WEST**Freeform Search**

Database: US Patents Full-Text Database
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Derwent World Patents Index
IBM Technical Disclosure Bulletins

Term: 17 and (octafluorocyclobutane or "c.sub.4 F.sub.8"
or perfluoropropylene or "C.sub.3 F.sub.6")

Display: 25 **Documents in Display Format:** CIT **Starting with Number** 1

Generate: ☐ Hit List ☒ Hit Count ☐ Image

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<u>DB Name</u>	<u>Query</u>	<u>Hit Count</u>	<u>Set Name</u>
USPT,PGPB	17 and (octafluorocyclobutane or "c.sub.4 F.sub.8" or perfluoropropylene or "C.sub.3 F.sub.6")	3	L9
USPT,PGPB	I6 same I7	5	L8
USPT,PGPB	trench same (side wall near4 polymer)	11	L7
USPT,PGPB	silicon same etch\$3	50168	L6
USPT,PGPB	I3 and (trench same side wall protect\$3)	0	L5
USPT,PGPB	I1 and I2	269	L4
USPT,PGPB	I1 same I2	88	L3
USPT,PGPB	silicon same (etch\$3 selectivity or etch\$3 stop)	4950	L2
USPT,PGPB	(potassium hydroxide or "KOH") same oxide	10960	L1

	L #	Hits	Search Text	DBs	Time Stamp
1	L1	9135	silicon same trench	USPAT ; US-PG PUB	2001/12/1 1 10:21
2	L2	6201	1 same etch\$3	USPAT ; US-PG PUB	2001/12/1 1 10:22
3	L3	621	(separat\$3 adj layer) same etch\$3	USPAT ; US-PG PUB	2001/12/1 1 10:35
4	L4	64	12 and 13	USPAT ; US-PG PUB	2001/12/1 1 10:45
5	L5	2	4 and sensor	USPAT ; US-PG PUB	2001/12/1 1 10:46